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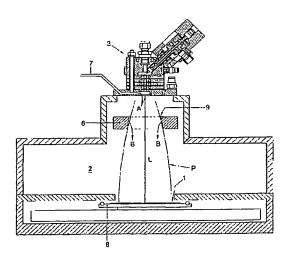
- (71) Applicant (for all designated States except US): OTB GROUP B.V. [NL/NL]; Luchthavenweg 10, NL-5657 EB Eindhoven (NL).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): BOXHOORN, Gosse [NL/NL]; Bongard 3, NL-6393 CH Wijnandsrade (NL). BIJKER, Martin, Dinant [NL/NL]; Betuwehof 64, NL-5709 KR Helmond (NL). EVERS, Marinus,

Franciscus, Johanus [NL/NL]; Ginderover 33, NL-5591 JM Heeze (NL). DINGS, Francisus, Cornelius [NL/NL]; Kapelstraat Noord 129, NL-5502 CC Veldhoven (NL).

- (74) Agent: PRINS, A.W.; NIEUWE PARKLAAN 97. NL-2587 BN DEN HAAG (NL).
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(54) Title: METHOD AND APPARATUS FOR MANUFACTURING A CATALYST



(57) Abstract: A method for manufacturing a catalyst, wherein a substrate (1) is introduced into a processing chamber (2, 102); wherein at least one plasma (P) is generated by at least one plasma cascade source (3, 103); wherein at least one deposition material (A, B) is deposited on the substrate (1, 101) under the influence of the plasma (P). The invention further provides an apparatus for manufacturing a catalyst, the apparatus being provided with at least one plasma cascade source (3, 103) for generating at least one plasma (P), the apparatus comprising means for bringing deposition material (A, B) into each plasma (P), the apparatus being further provided with substrate positioning means (8, 118) to bring and/or keep at least a part of a substrate (1, 101) in such a position in a processing chamber (2, 102) that the substrate (1, 101) makes contact with the plasma (P).